## PATENT APPLICATION

Sheet 1 of 1

					ATTY. DOCKET NO.		SERIAL NO.			
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LIST OF PATENTS AND PUBLICATIONS FOR APPLICANT'S INFORMATION DISCLOSURE STATEMENT  (Use several sheets if necessary)					APPLICANT				PTG	
					Duane Fasen et al.		468			
					FILING DATE		GROUP			
					Herewith				86	
REFEREN	CE D	ESIGNATION	U.S. PA	ATEN	T DOCUMENTS				010	
EXAMINER INITIAL		DOCUMENT DATE			NAME		CLASS		SUB CLASS	
VAMS	1A	6,184,055	Feb. 6, 2001	Yaı	ng et al.					
VAMS	1B	6,060,732	May 9, 2000	Ми	ırakami et al.					
VAMS	1C	6,048,662	Apr. 11, 2000	Bru	uhnke et al.				<del></del>	
VAMJ	1D	5,990,506	Nov. 23, 1999	Fo	ssum et al.					
VAMJ	1E	5,654,202	Aug. 5, 1997	Da	ly et al.					
VAMI	1F	4,855,199	Aug. 8, 1989	Во	lon et al.					
VAMS	1G	4,782,009	Nov. 1, 1988	Во	lon et al.					
	1H									
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		DOCUMENT NUMBER	DATE		N PATENT DOCUMENTS NAME	CLASS	SUB CLASS	TRAN	SLATION	
	1L							↓—		
	1M							<del> </del>		
	1N									
	10									
	1P								<u> </u>	
	•	OTHER RE	FERENCES (includ	ing A	uthor, Title, Date, Pertin	ent Pages	, etc.)			
 AMJ	10	"Production metrology and control of color filter array photolithography for CMOS imagers," SPIE Vol. 3677, pp. 326-337 (1999).								
JAMS	1R	"Color filter array for CCD and CMOS image sensors using a chemically amplified, thermally cured, pre-dyed, positive-tone photoresist for 365 nm lithography," SPIE Vol. 3678, pp. 1083-1090 (1999).								
 IAMS	15	"Advanced complementary color filter technology without dyeing process for CCD image sensors," SPIE Vol. 3333, pp. 1232-1240 (1998).								
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